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Fourier-Transformed Temperature-Dependent Photoluminescence of CaSh-Based Resonant Tunneling Structure

of GaSb-Based Resonant Tunneling Structure with GaInAsSb Absorption Layer

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The band structure of type-II resonant tunneling structures with a quaternary GaInAsSb absorption layer was studied by means of Fourier-transformed photoluminescence in the mid-infrared spectral region. The temperature-resolved measurement revealed a low-energy band with non-trivial photoluminescence spectra evolution. At low temperature the emission originating from the confined states within the type II GaSb/AlSb/InAs quantum well dominates the spectrum. The increase of temperature triggers the hole transfer from the GaSb quantum wells to the heavy hole band edge of the quaternary GaInAsSb material. The GaInAsSb-related emission line arises at 130 K and gains in intensity up to room temperature.

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1. Introduction

Resonant tunneling structures (RTS) play an important role in a large variety of nowadays electronic and optoelectronic semiconductor devices. Besides being applied in high-speed electronic circuits, resonant tunneling is the basic underlying physical principle used in various other optoelectronic devices. Conventional RTS's based on GaAs or InP material systems are employed e.g. in active regions of quantum cascade lasers (QCLs) [1], THz oscillators [2, 3], and high-gain photodetectors [4, 5] with the possibility of single photon detection [6], as well as in nanothermometers [7].

Compared with conventional RTS's, the InAs-GaSb-AlSb material system offers a broad spectrum of bandgap energies and band alignments from staggered (type-I) to broken (type-II) [8]. The latter is of particular interest as it provides possibility of covering the mid-infrared spectral range as an active region of interband cascade lasers (ICLs) and interband cascade detectors (ICD) [9]. Despite the advantage of flexibility for band gap engineering, the broken-gap alignment suffers from reduction of the oscillator strength, determining the gain of the medium. Substantial work was required, comprising the methods of optical spectroscopy, in order to understand

On the other hand, there is very little information available on the exact energy structure of radiation detectors utilizing the type-II RTS. Such structures, with an Sb-based tunneling region [14, 15], are of great demand for high-speed and low-power requiring applications. The low power consumption arises because the negative resistance peak in the Sb-based material system occurs near 100 meV, whilst the conventional GaAs-based RTS generally requires the bias of several volts [8]. The Sb-RTS's also exhibit high peak current densities near $100~{\rm A/cm^2}$ that are desirable for high-speed applications, and large peak-to-valley current ratios as high as 20 at room temperature, that help to minimize power dissipation [8].

In this work, we present a comprehensive investigation of the energy band structure of the type-II RTS with an adjacent quaternary bulk layer. Similar material combination utilizing type-I GaAsSb/AlAsSb quantum wells (QW) with a GaInAsSb absorption layer was recently successfully reported as a photodetector operating in the mid-infrared spectral range [16, 17]. Due to the complicated band alignment of such systems in the vicinity of RTS's, as well as the possibility of interface layer formation, the structure under investigation exhibits non trivial photoluminescence (PL) behavior. The PL signal is measured in a wide range of sample's temperatures

the complex band structure of multilayered ICLs [10–12]. As a result of extensive studies, the ICLs exhibit a state-of-the-art performance in the spectral region of mid-infrared [13].

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in order to determine the origin of constituent emission lines forming the emission spectrum. The analysis of the obtained data, together with theoretical simulations, provides the full picture of the band structure necessary for optimization of the fabrication of GaSb-based RTS's, which are expected to supplant the GaAs-based devices in terms of range of operating temperatures and power consumption.

2. Investigated structures and experimental details

The structure under investigation is a GaSb-based RTS grown by the molecular beam epitaxy. On top of a substrate, a $2 \times 10^{18} \text{ cm}^{-3} p$ -doped 300 nm thick GaSb bottom contact layer is deposited and followed by a 2×10^{17} ${\rm cm}^{-3}$ p-doped 30 nm thick GaSb transition layer and a 30 nm GaSb buffer layer. The active region contains of the RTS and a quaternary bulk-like absorption layer. The latter one is formed of 600 nm thick GaInAsSb. The In and As contents of 24% and 20%, respectively, resulted in a negligible lattice mismatch with respect to GaSb. Finally, a 295 nm thick 2×10^{18} cm⁻³ p-doped GaSb top contact layer is grown. The structure is finalized with a 10 nm InAs cap. The design of the resonant part is constituted by an AlSb/InAs/GaSb/AlSb/InAs/GaSb double barrier structure forming two asymmetric InAs and one GaSb QWs. The width of consecutive layers equals to 2/1.5/3/2/2.5/5 nm, respectively. The band alignment of the RTS, including a ≈ 4 nm fraction of the 600 nm quaternary absorption layer, is presented in Fig. 1.

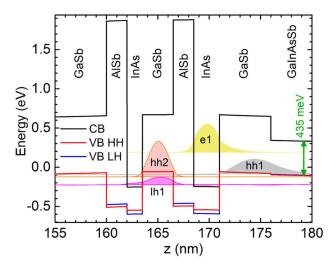


Fig. 1. Band alignment of the resonant tunneling part with a fraction of the GaInAsSb absorption layer. The conduction, heavy hole and light hole band edges are presented in black, red and blue, respectively. Colored areas indicate the probabilities for electron (e1) and holes (hh1, hh2 and lh1).

Photoluminescence studies in the spectral region of mid-infrared are performed with a Fourier transform infrared spectrometer operating in the step-scan mode. The phase sensitive detection scheme utilizes a lock-in amplifier. The pump beam is mechanically chopped at a reference frequency of 360 Hz and focused onto the sample to the spot of 1 mm². The spectra are measured with a spectral resolution of 64 cm⁻¹, and the signal on the detector is averaged over time in order to improve the signal-to-noise ratio. To realize that, a standard procedure is employed where the spectrometer's mirror is fixed at each position for a time of 500 ms. The temperature-resolved photoluminescence studies are performed with a continuous-flow liquid helium cryostat equipped with CaF₂ windows.

3. Results and discussion

Figure 2 presents the evolution of the PL spectra in a wide temperature range from 15 to 300 K. Two emission bands are visible: the low-energy one spreading from 300 to 500 meV and a high-energy one, at about 780 meV. The former contains five distinct maxima labeled I_0 – I_4 , respectively. At low temperature (the topmost spectrum) the I_4 dominates, whereas the I_0 is the least visible feature. Both emission peaks vanish with temperature, the I_0 at 100 K and the I_4 at 75 K. On the other hand, the emission peaks labeled I_1 , I_2 and I_5 persist up to the room temperature. At elevated temperature of 180 K the I_3 peak emerges and dominates the PL spectrum at room temperature. The I_5 emission peak originates from the GaSb substrate.

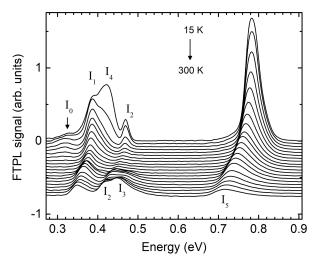


Fig. 2. PL spectra measured in a wide range of temperatures from 15 to 300 K.

In order to determine the emission parameters of the I_0 – I_5 peaks, each spectrum is fitted with the respective number of Gaussian functions. Figure 3a shows the decomposition of PL spectrum measured at low temperature (30 K) with five Gaussian peaks (colored area) standing for the I_0 , I_1 , I_2 , I_4 and I_5 emission lines. A red dotted line stands for the cumulative fit. The asymmetry of the I_1 emission peak at the high energy side originates from the additional emission line labeled I_4 . The

room temperature PL response is presented in Fig. 3b. The emission peaks are broadened and the thermal highenergy tail is present (i.e. see peak labeled I_5). Due to the contribution of hot carriers the spectra are fitted with exponentially modified Gaussian function — a convolution of an exponential decay originating from the k_BT tail and the symmetric Gaussian function. The cumulative fit (red dashed curve) shows good agreement with measured data.

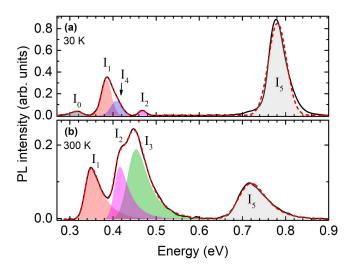


Fig. 3. The PL spectrum at 30 K (a) and 300 K (b). Colored areas represent the fitting results of individual emission lines. Red dotted line stands for cumulative fit.

In order to understand the origin of the I_0 – I_4 emission lines the band structure was modeled in the framework of an 8-band kp model with the commercial nextnano software [18]. Figure 1 shows the band alignment of the resonant-tunneling section of the structure under investigation, containing type-II AlSb/InAs/GaSb QW, as well as GaSb buffer layers and a fraction of the 600 nm wide quaternary GaInAsSb absorption layer. The confined states of electrons and holes and the respective probability densities are calculated. The ground electron state is localized mainly in the 2.5 nm wide InAs QW. The holes of interest (i.e. with substantial squared overlap integral with the e1 state) reside in two subbands. The ground state (hh1 in grey) is located in a shallow, 5 nm wide GaSb QW, with InAs and GaInAsSb heavy hole band edges creating a confining potential of 10 meV. The second subband contains the hh2 and lh1 states, in red and magenta respectively, and is located in the 3 nm wide GaSb QW.

The calculated values (dashed lines) of transition energies are compared with the ones obtained from the fitting procedure in Fig. 4a. According to the band structure simulations, the I_1 emission line (red diamonds) corresponds to the e1–hh2 optical transition in the type-II InAs/GaSb quantum well, whereas the origin of I_2 emission peak is still under investigation. The possible explanations are the e1–lh1 transition (magenta) within the same QW and/or the transition involving the light hole

subband of the quaternary GaInAsSb layer. The I_1 and I_2 transitions are visible in the whole range of the measurements temperature. At low temperature (see Fig. 3a) the I_0 emission line is present at the low energy side of the spectrum corresponding to the e1–hh1 transition. The I_3 emission peak, dominating the PL spectrum at room temperature (see Fig. 3b), originates from the quaternary $Ga_{0.76}In_{0.24}As_{0.2}Sb_{0.8}$ bulk layer.

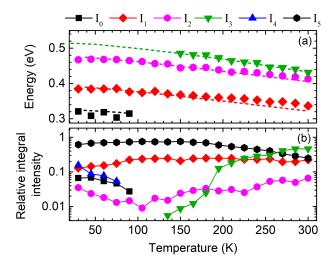


Fig. 4. (a) The transition energies extracted from fits to the PL spectra in function of sample temperature. Dashed curves represent the results of computer simulations. (b) Relative integral intensities as a function of sample's temperature.

Figure 4b presents the relative integral intensities defined as the ratio of the area of individual peak to the total area of the cumulative fit. The change of temperature from 15 to 300 K triggers the hole transfer within the sample. In the range of low temperatures, from 15 to 100 K, the I_0 emission line exhibits an efficient thermal quenching due to the shallow confining potential for the hh1 state in the GaSb QW. The I_0 emission line disappears completely at ≈ 100 K, which, translating to the thermal energy scale, gives 8.5 meV activation energy a value reasonably close to the QW depth of 10 meV. As the holes from GaSb (from the GaSb QW as well as from the GaSb top contact layer) are thermally activated to the heavy hole band edge of GaInAsSb, the I_3 emission line, corresponding to the GaInAsSb material, arises at approximately 130 K. At the temperatures above 150 K, the intensity of the I_1 peak, attributed to the e1 to hh2 transition, remains nearly constant, whereas the I_2 emission line, representing the e1-lh transition, exhibits a rising trend. The origin of the I_4 emission line is still not fully clear yet, however the possible explanation is that it comes from the InAs cap layer.

4. Conclusions

We have investigated a GaSb-based type-II resonant tunneling structures with the GaInAsSb absorption layer by means of temperature-dependent photoluminescence supported by band structure modeling. The PL spectra revealed low-energy emission band containing five peaks, whose evolution was studied in function of temperature. At low temperature the emission originates mostly from the confined states in the type-II InAs/AlSb/GaSb quantum well within RTS and a shallow InAs/GaSb QW adjacent to the GaInAsSb layer. The confinement potential for the shallow GaSb QW was determined to be 8.5 meV, in agreement with the calculated confined levels' structure. At about 130 K, the emission from the quaternary GaInAsSb bulk layer arises, dominating the photoluminescence spectrum at room temperature.

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